



Development of Time-Of-Flight Neutron Depth Profiling at Penn State University - Preliminary Results

Sacit M. Çetiner
Kenan Ünlü

Penn State University
Radiation Science & Engineering Center
University Park, PA 16802-2304

Gregory R. Downing
NIST

TRTR-IGORR 2005
Gaithersburg, MD
September 12-16, 2005



INTRODUCTION

- Neutron depth profiling (NDP)
- Conventional NDP
 - limitations
- Penn State NDP Setup
- Time-of-Flight NDP (TOF-NDP)
 - need
 - possibilities
- Penn State TOF-NDP Setup
- Preliminary Results



NEUTRON DEPTH PROFILING

- Neutron depth profiling
 - powerful surface characterization technique for certain light elements
 - monoenergetic, isotropic charged particle emission
 - rapid energy loss
 - nondestructive
- Conventional neutron depth profiling (NDP)
 - direct measurement of residual energy
 - SBD, PIPS or Photodiode PIN detectors
- Time-of-Flight NDP
 - particle flight time is measured
 - microchannel plates (MCP) can be used

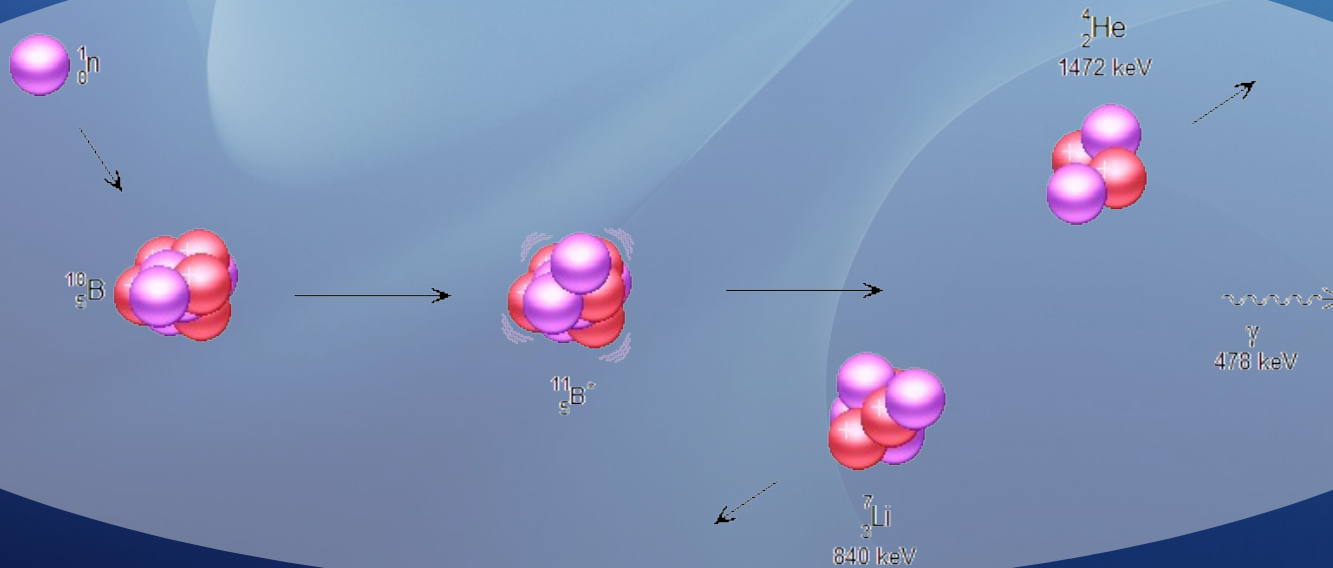
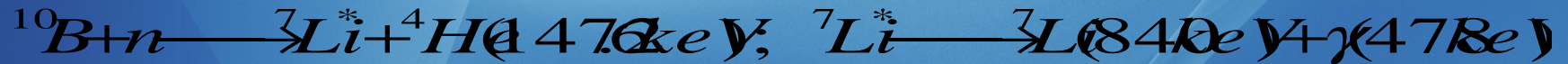


APPLICATIONS OF NDP

- B depth profile in insulation layers such as *borophosphosilicate glass* (BPSG), and implanted B distributions of semiconductor wafers
- He dynamics in technologically important materials
- Li depth profile in lithium niobate (LiNbO_3) optical waveguide
- He damage and effusion in fully stabilized zirconia
- Li and N profiles in lithium phosphorus oxynitride (LiPON), and Li profile in lithium cobaltoxide (LiCoO_2), two important lithium-ion battery materials

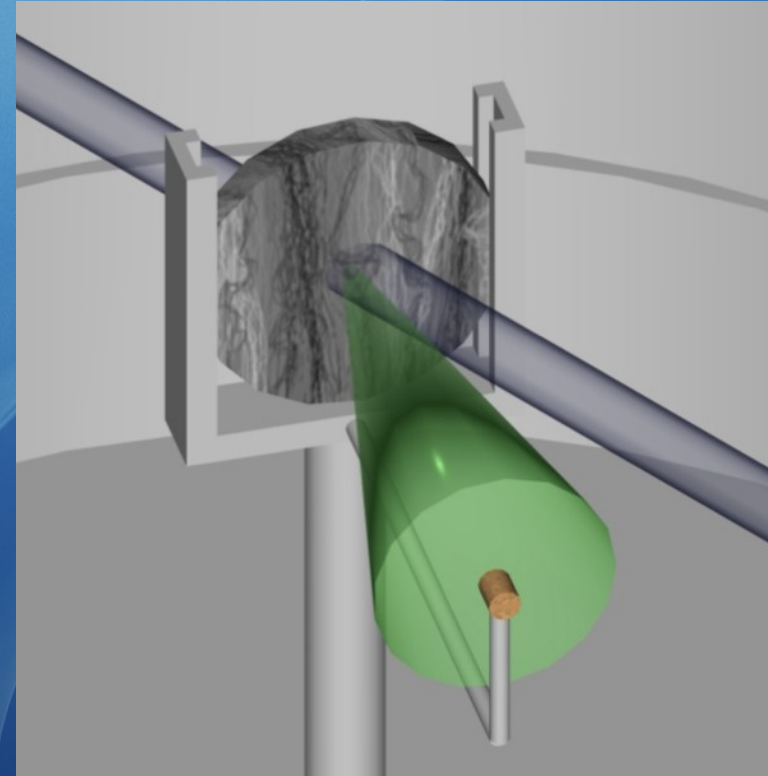
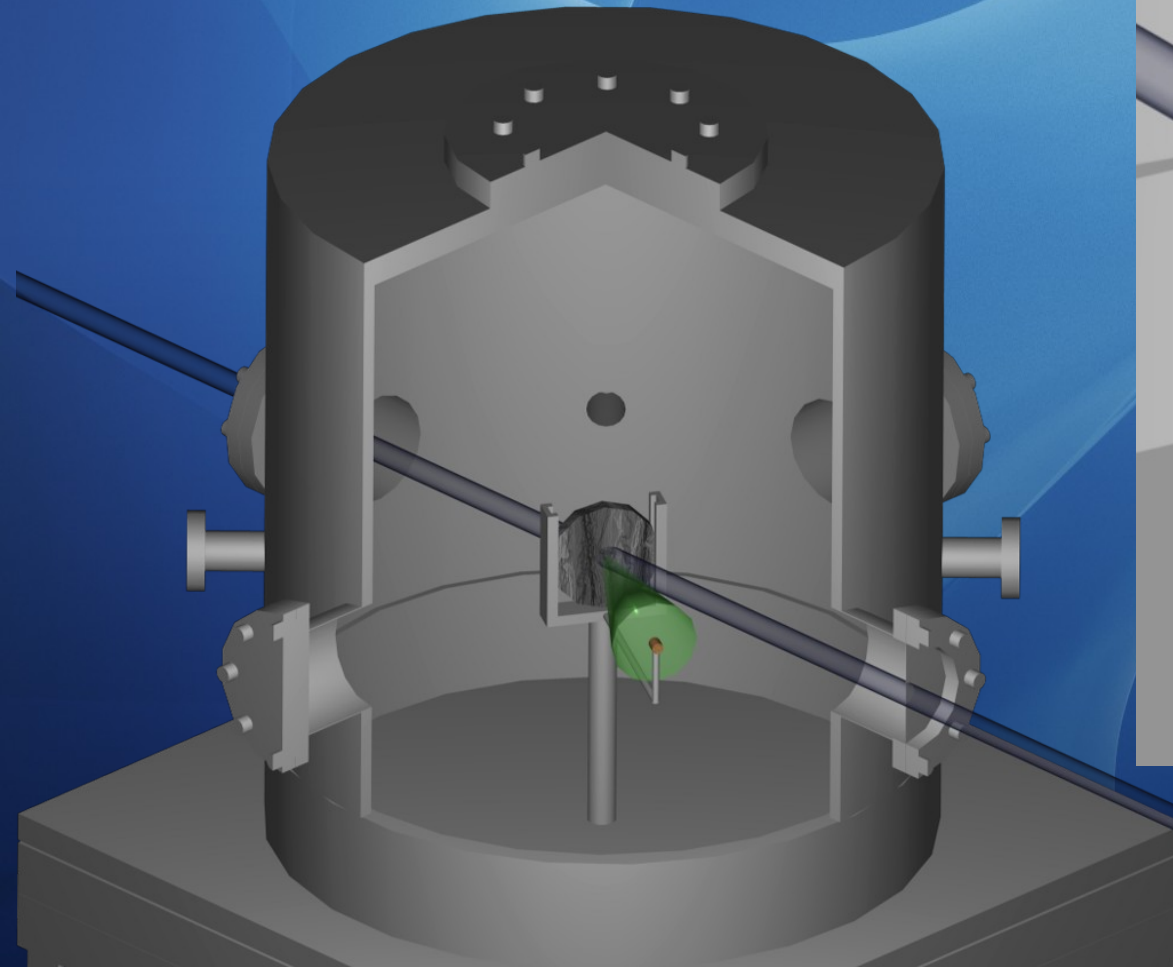


NEUTRON DEPTH PROFILING



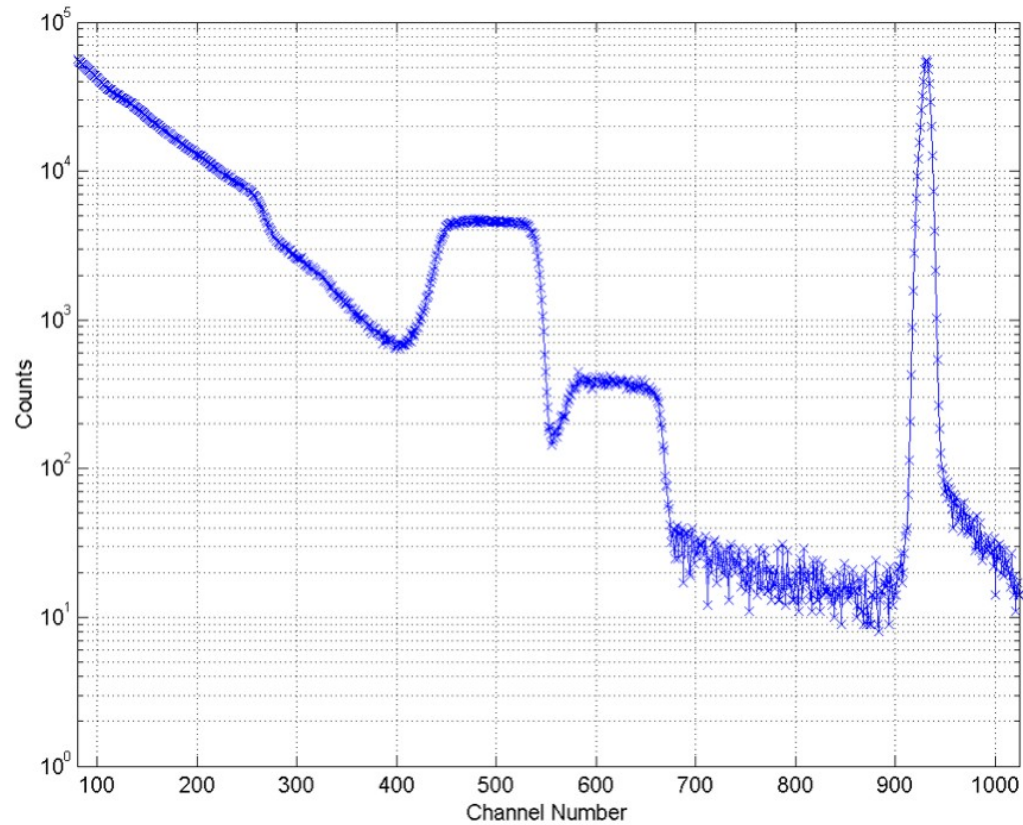


PENN STATE NDP SETUP



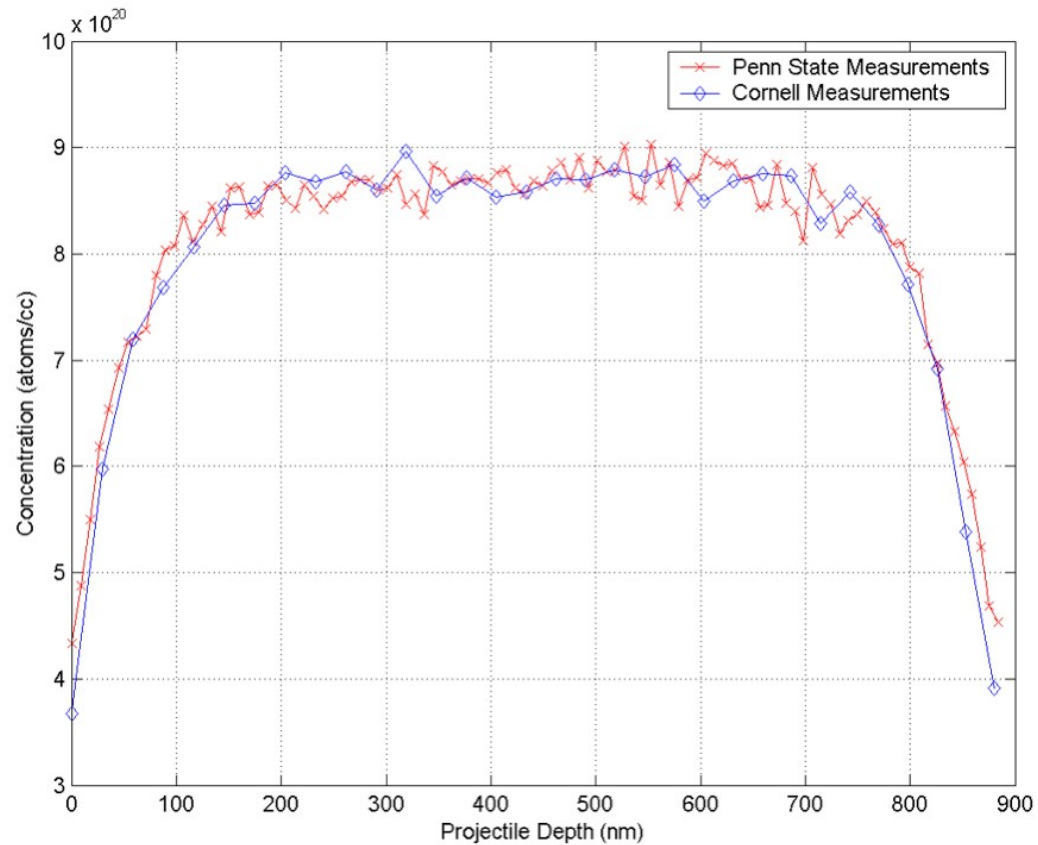


BPSG STANDARD SAMPLE





BPSG STANDARD SAMPLE



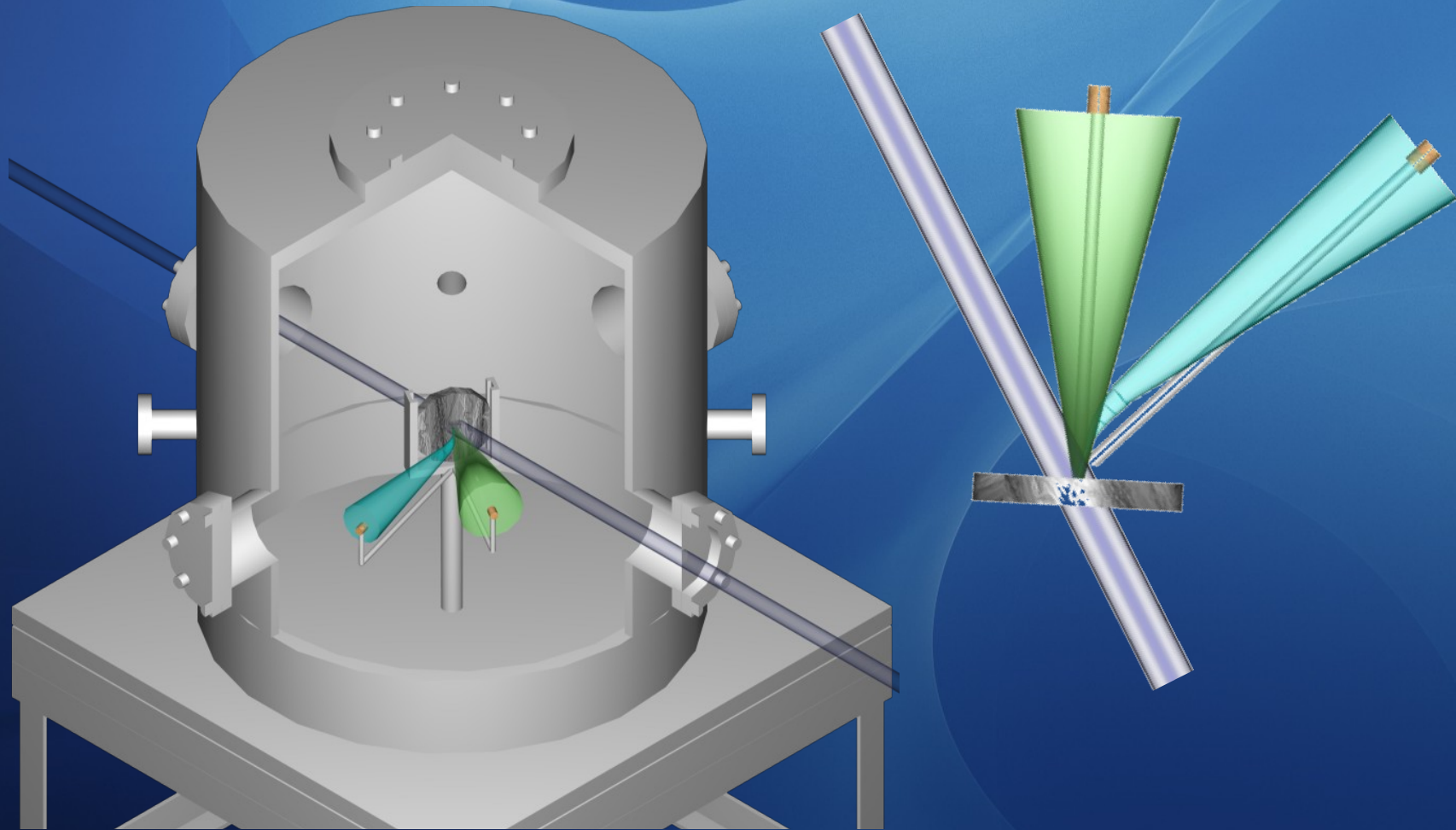


TIME-OF-FLIGHT NDP

- Particle flight time is measured, which is inversely proportional to particle residual energy
- Instead of semiconductor detectors, microchannel plates (MCP) can be used for precise time signals
- Secondary electrons ejected from the surface of the sample as the charged particle emerges are used to trigger the start signal; alpha or recoil give the stop signal



PENN STATE TOF-NDP SETUP



September 12-16, 2005

TRTR-IGORR 2005

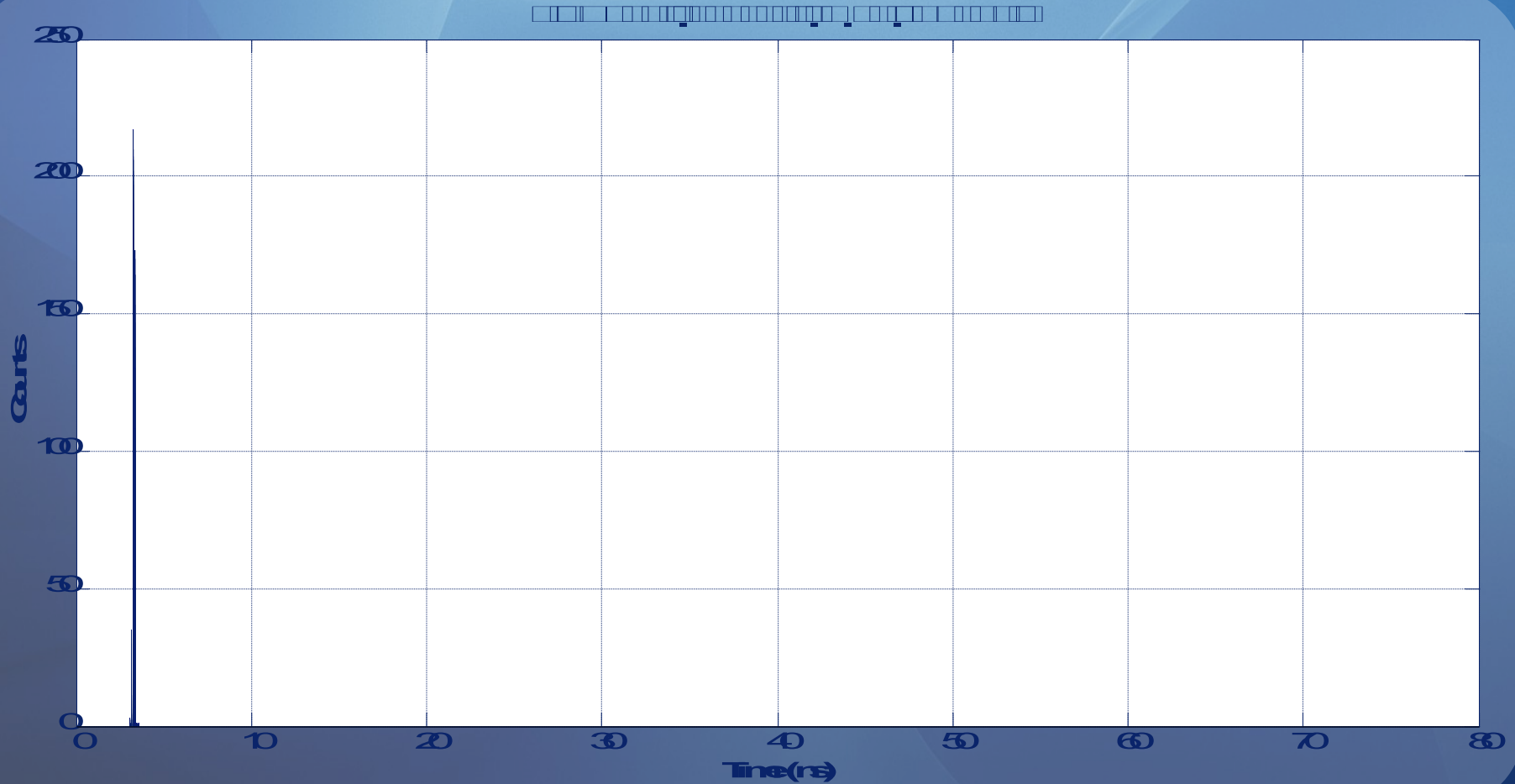


TIME-OF-FLIGHT NDP

- Time-of-NDP is particularly important for depth profile measurements of shallow and ultra shallow source/drain junctions
 - device thickness < 200 nm

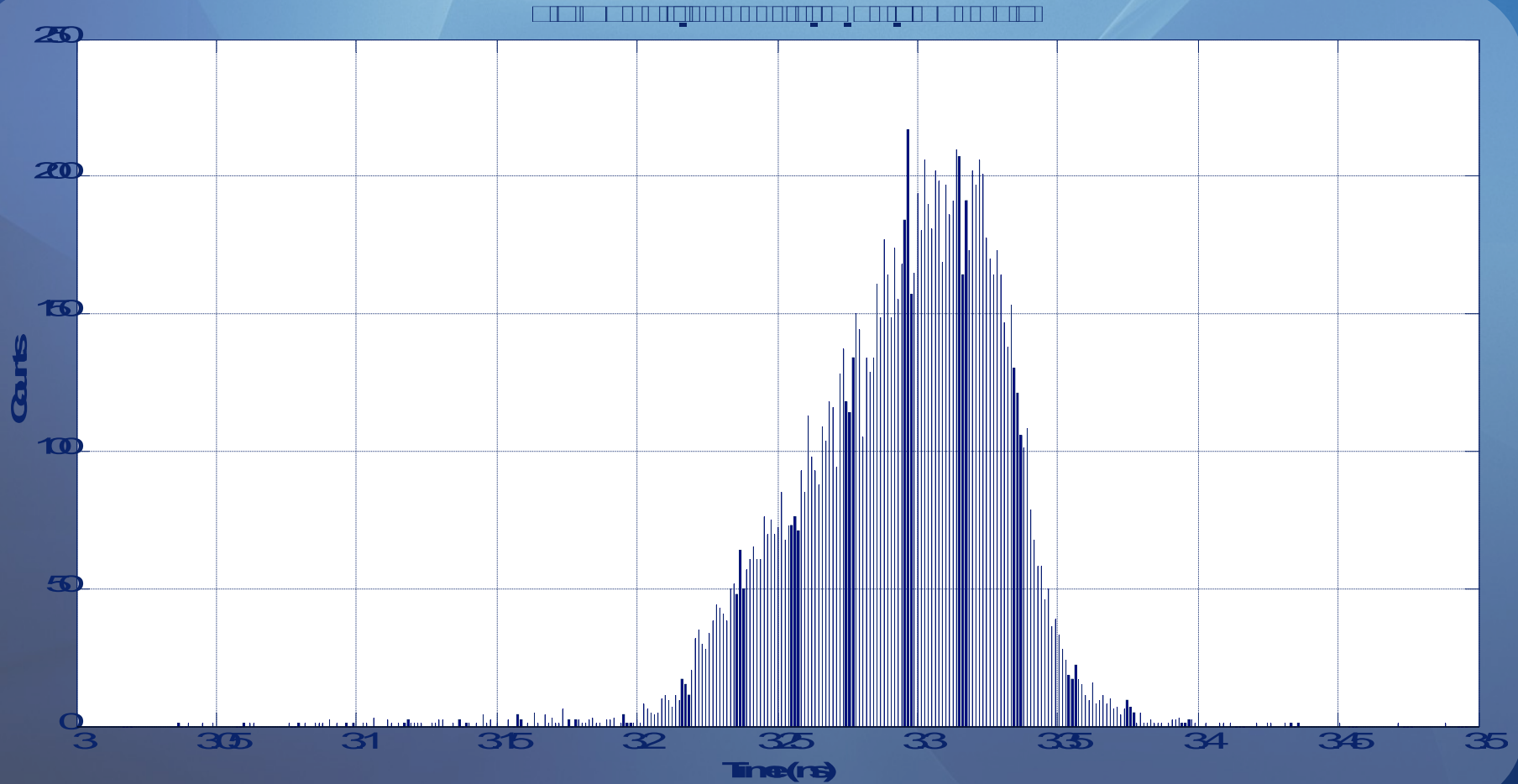


TIME-OF-FLIGHT NDP: Preliminary Measurements - Offline



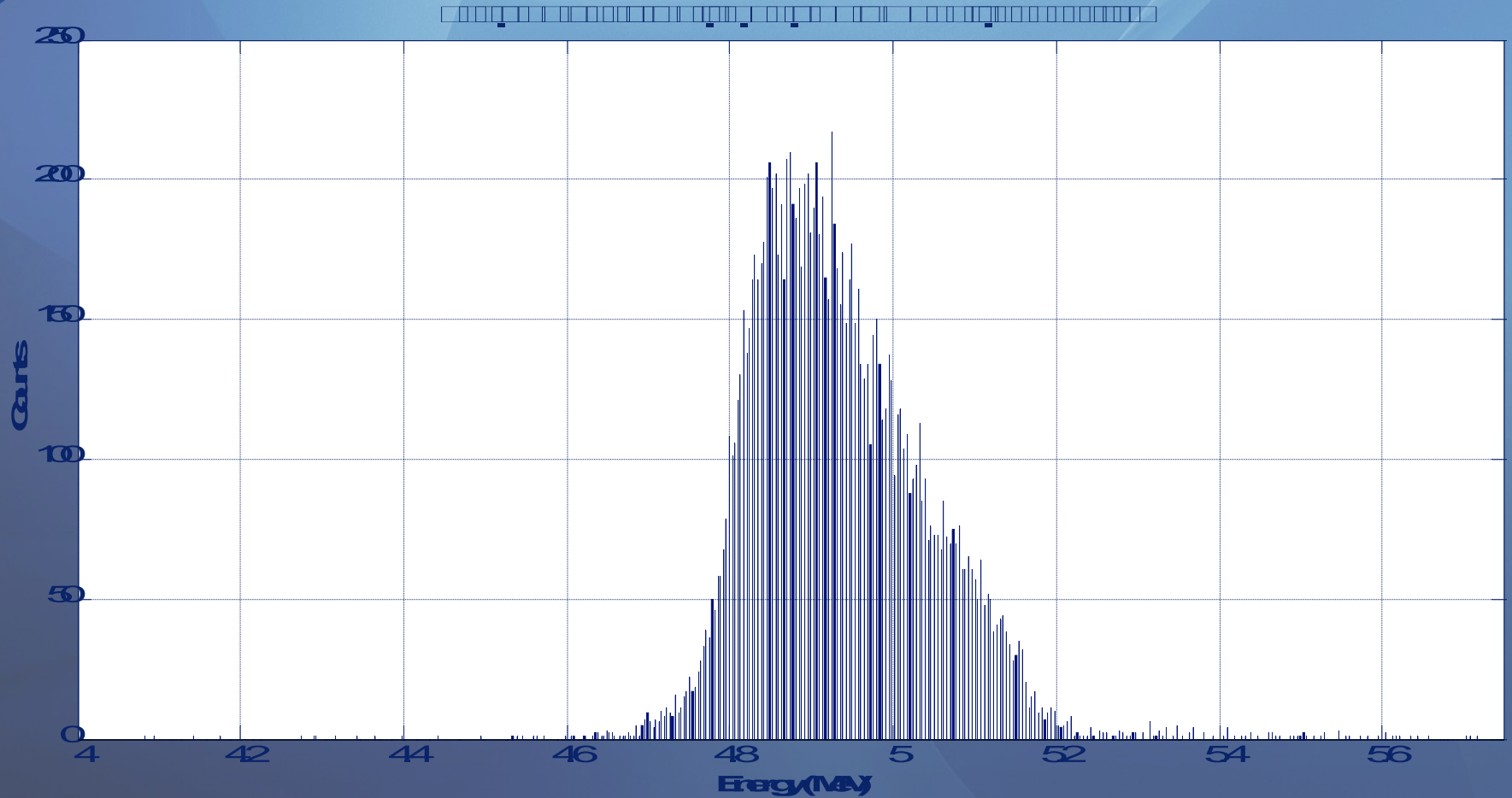


TIME-OF-FLIGHT NDP: Preliminary Measurements - Offline



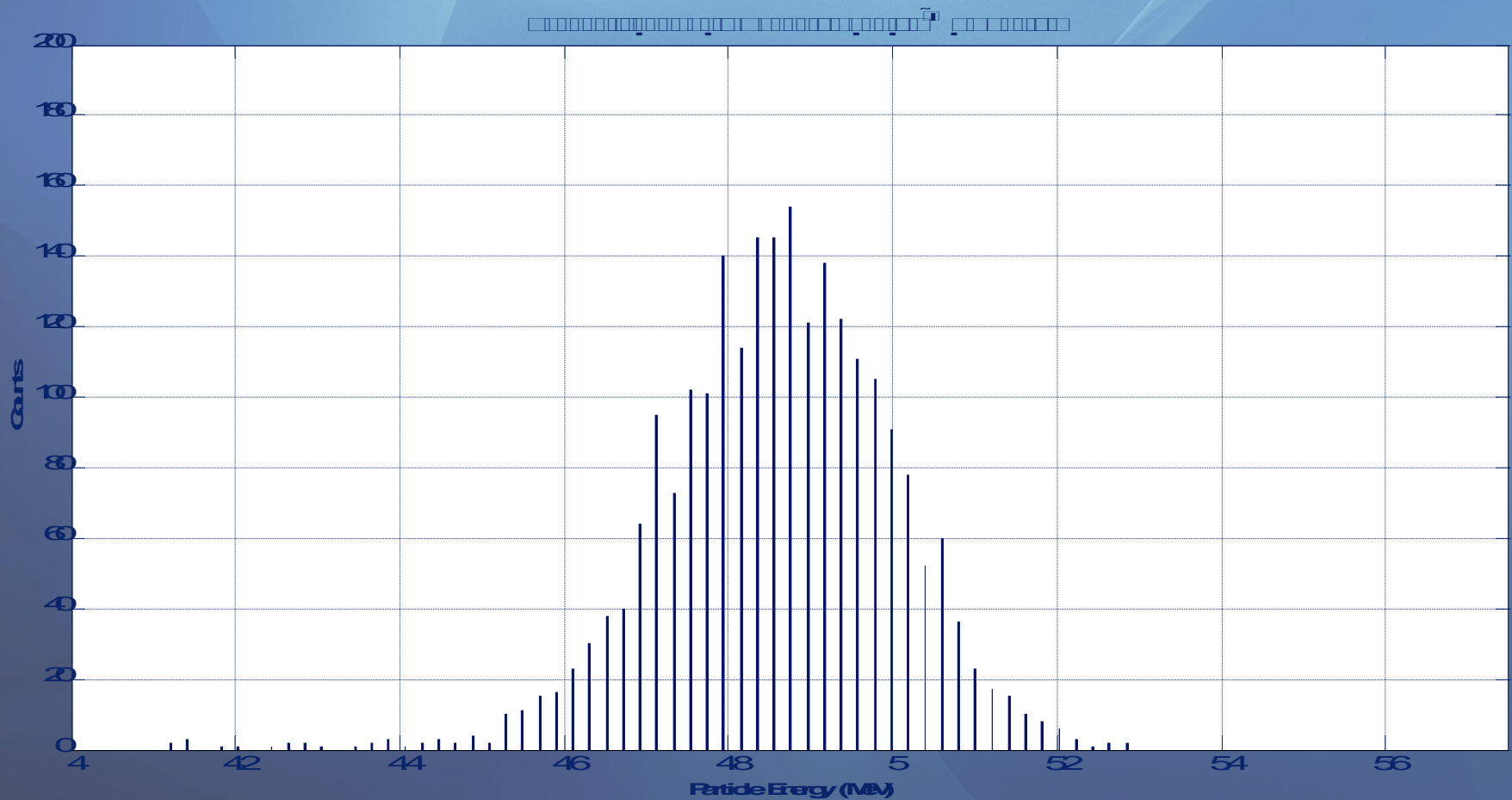


TIME-OF-FLIGHT NDP: Preliminary Measurements - Offline





CONVENTIONAL NDP: Same Sample



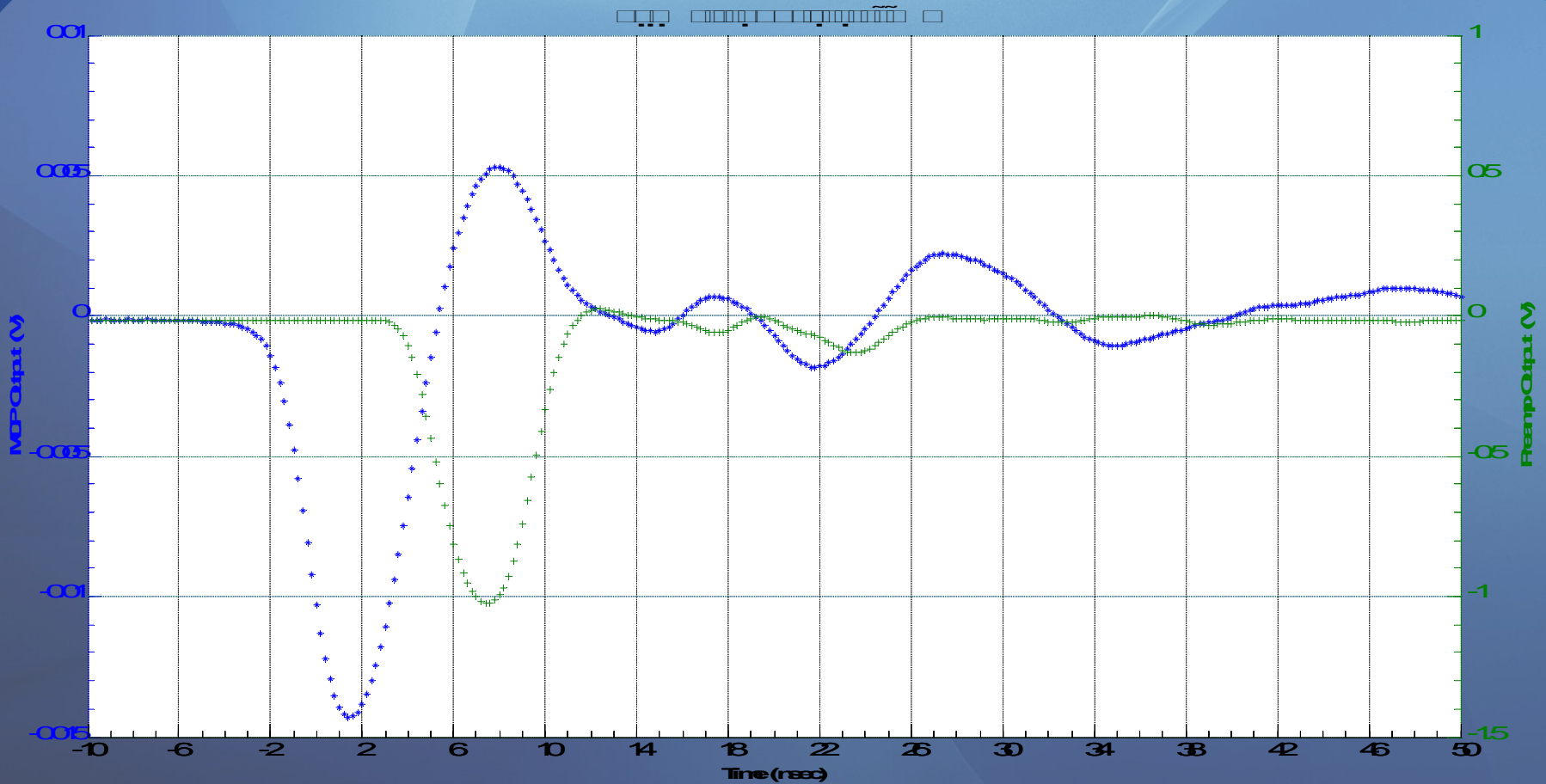


HOW TO IMPROVE

- Noise elimination
- Impedance matching along the entire signal transmission line
- Microchannel plate (MCP) assembly: special conical anode

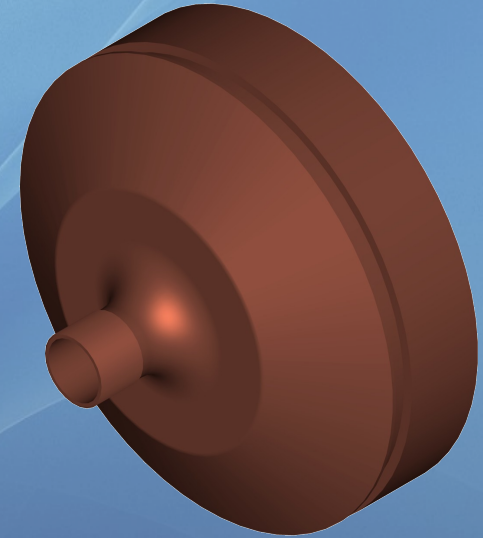
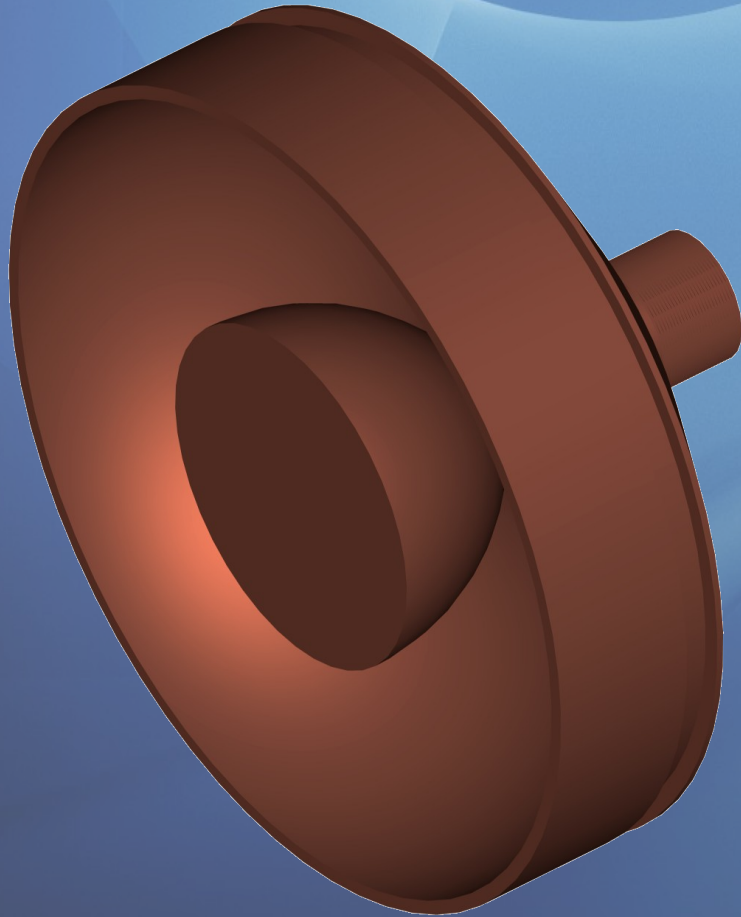


MCP SIGNAL





Signal Improvement: Special Conical Anode



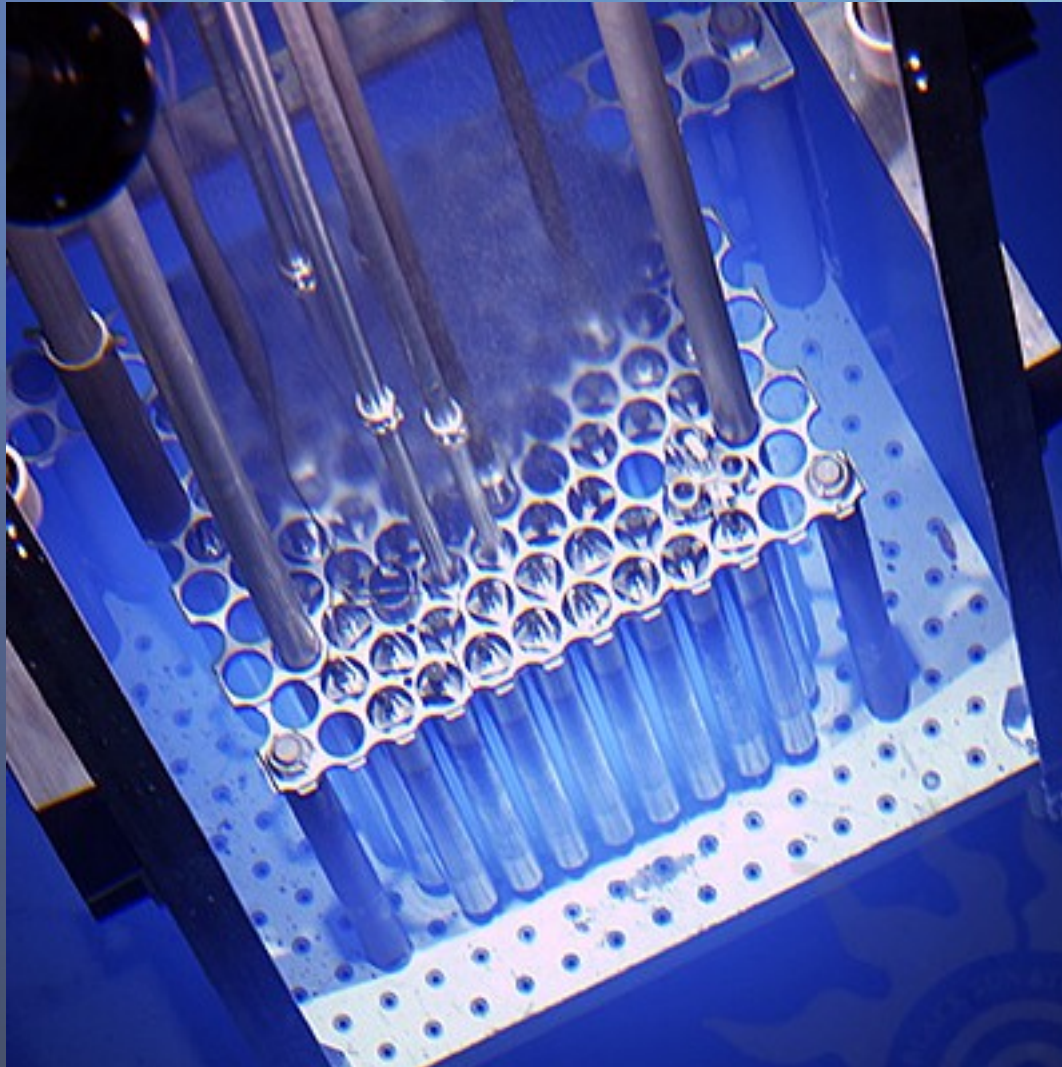


SUMMARY

- Preliminary measurement results have been presented
- Further optimization is needed for higher signal resolution
- Improved depth resolution will make it possible to measure B depth profiles in ultra shallow junctions



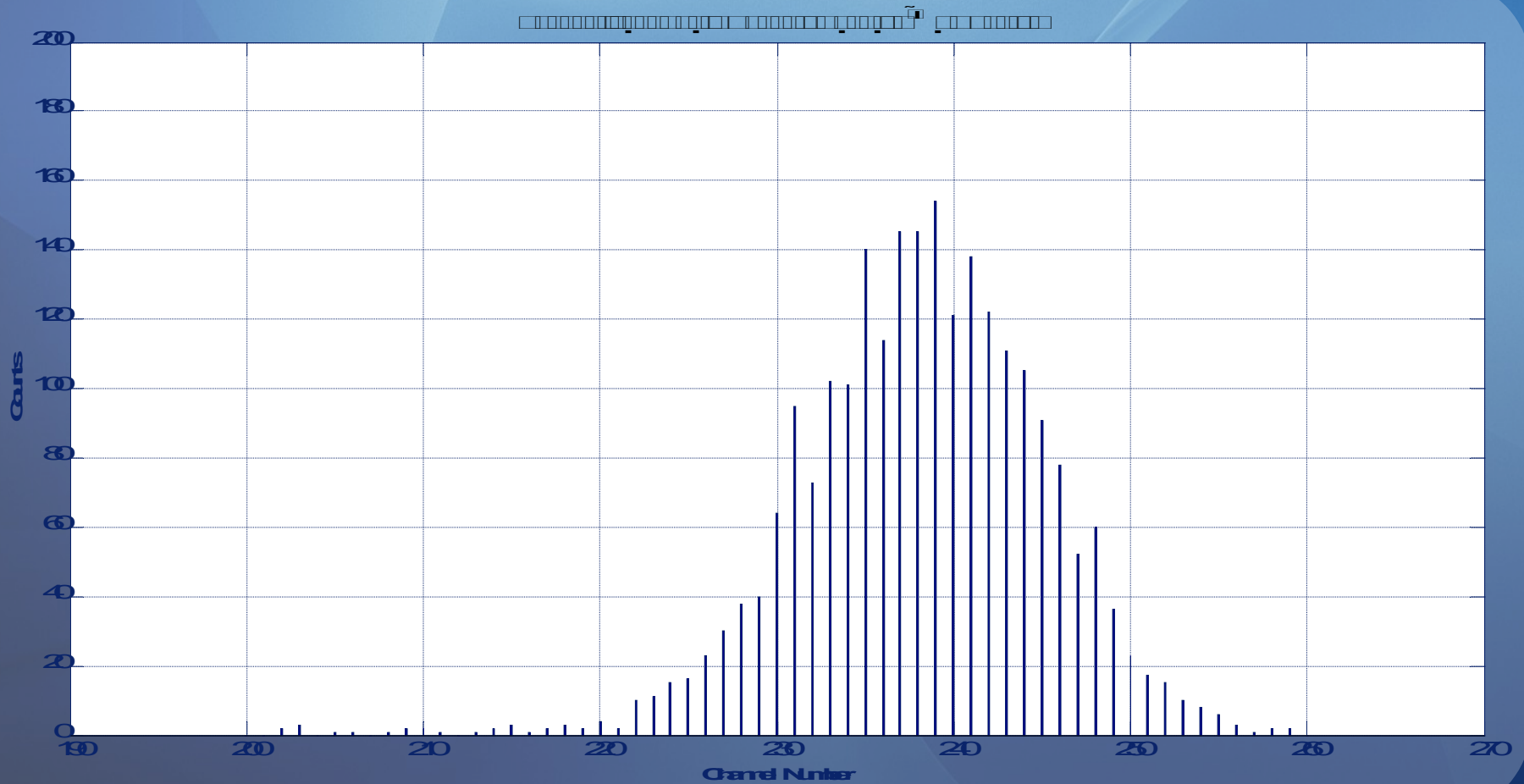
THANK YOU!



Penn State
Breazeale Nuclear
Reactor during a pulse

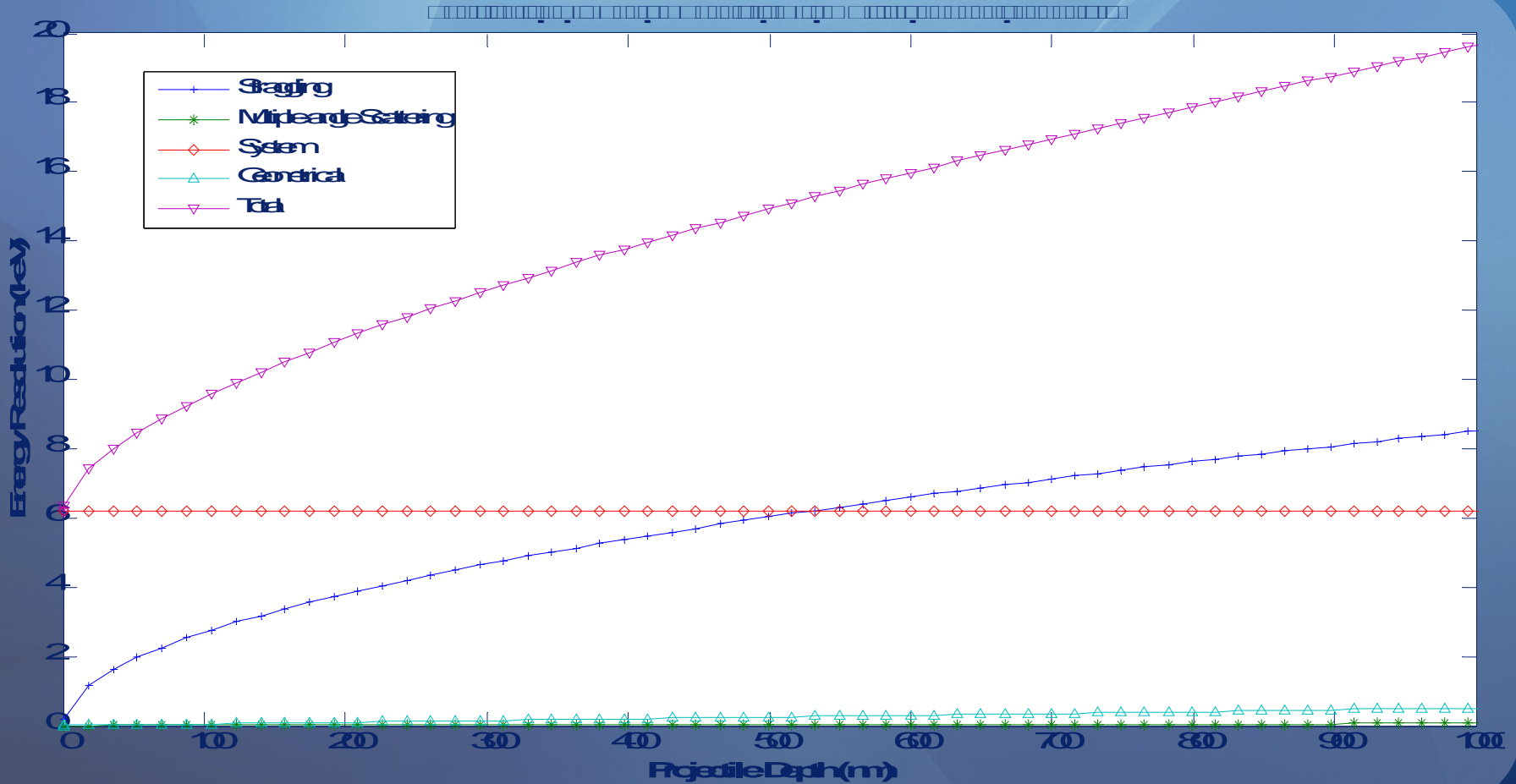


CONVENTIONAL NDP: Same Sample





TIME-OF-FLIGHT NDP





TIME-OF-FLIGHT NDP

